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IN THE CLAIMS:

Please CANCEL claims 9-13, without prejudice or disclaimer, as these claims were withdrawn from consideration.

Please AMEND the claims and ADD new claims as indicated below:

1. (CURRENTLY AMENDED) A gas discharge panel substrate assembly comprising:

electrodes formed on a substrate,

a dielectric layer covering the electrodes, and

a protective layer covering the dielectric layer and in contact with a discharge space, wherein

the protective layer includes MgO and at least one compound selected from the group consisting of an Al compound, a Ti compound, a Y compound, a Zn compound, a Zr compound, a Ta compound and SiC having an ultraviolet shielding function, and

the dielectric layer is a CVD film.

- 2. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 1, wherein the protective layer comprises a layer which shields from does not transmit light having a wavelength of 200 nm or less.
- 3. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 1, wherein said at least one compound selected from the group consisting of an Al compound, a Ti compound, a Y compound, a Zn compound, a Zr compound, a Ta compound and SiC is a compound having a bandgap of 6.2 eV-or-less.
- 4. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 1, wherein the dielectric layer contains a low-melting glass or CVD-SiO₂.
- 5. (CURRENTLY AMENDED) A gas discharge panel substrate assembly comprising:

electrodes formed on a substrate,

a dielectric layer <u>formed on the substrate so as to covering cover</u> the electrodes <u>and</u> <u>made of a CVD film</u>,

an ultraviolet shielding layer formed on the dielectric layer and made of a compound

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having an ultraviolet shielding function, and

a protective layer formed on the ultraviolet shielding layer and made of MgOan intermediate layer covering the dielectric layer, and a protective layer covering the intermediate layer and in contact with a discharge space, wherein the protective layer includes MgO and the intermediate layer includes at least one compound selected from the group consisting of an Al compound, a Ti compound, a Y compound, a Zn compound, a Zr compound, a Ta compound and SiC.

- 6. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 5, wherein said at least one compound is selected from the group consisting of an AI compound, a Ti compound, a Y compound, a Zn compound, a Zr compound, a Ta compound and SiC-is a compound having a bandgap of 6.2 eV or less.
- 7. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 5, wherein the intermediate ultraviolet shielding layer comprises a layer which shields from does not transmit light having a wavelength of 200 nm or less.
- 8. (CURRENTLY AMENDED) A gas discharge panel substrate assembly of claim 5, wherein the dielectric layer contains a low-melting glass or CVD-SiO₂.
 - 9. (CANCELED)
 - 10. (CANCELED)
 - 11. (CANCELED)
 - 12. (CANCELED)
 - 13. (CANCELED)
- 14. (ORIGINAL) An AC type gas discharge panel using the gas discharge panel substrate assembly as disclosed in claim 1 as a gas discharge panel substrate assembly in the front side.
- 15. (ORIGINAL) An AC type gas discharge panel using the gas discharge panel substrate assembly as disclosed in claim 5 as a gas discharge panel substrate assembly in the front side.

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- 16. (NEW) A gas discharge panel substrate assembly comprising:
 electrodes formed on a glass substrate;
 a dielectric layer made of a sheet frit glass formed on the substrate by baking;
 an intermediate layer formed on the dielectric layer and shielding vacuum
 ultraviolet light from a discharge space; and
 a protective layer covering the intermediate layer and made of MgO.
- 17. (NEW) A gas discharge panel substrate assembly of claim 16, wherein the intermediate layer is made of at least one compound selected from the group consisting of an Al compound, a Ti compound, a Y compound, a Zn compound and a Ta compound.
- 18. (NEW) A gas discharge panel substrate assembly of claim 16, wherein the intermediate layer is a ZrO₂ layer.